

DEC 29 2006

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FACSIMILE COVER LETTER

To: Commissioner for Patents
Examiner Jesse A. Fenty

Firm: U.S. Patent and Trademark Office
Art Unit 2815

Facsimile: (571) 273-8300

From: Grace L. Pan

Date: December 29, 2006

Re: FLH Ref No.: 790001-2042
Serial No: 10/752,642

Number of Pages: 8
(including cover page)

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00419829

U.S. Application No. 10/752,642
Reply to Office Action mailed November 2, 2006

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PATENT
790001-2042

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s) : Naofumi Nakamura et al.
Serial No. : 10/752,642
For : SEMICONDUCTOR DEVICE AND METHOD OF
FABRICATING THE SAME
Filing Date : January 7, 2004
Examiner : Jesse A. Fenty
Group Art Unit : 2815
Confirmation No. : 4109

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BERNADETTE VASSALLO

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Signature

December 29, 2006

Date of Signature

745 Fifth Avenue
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RESPONSE

MAIL STOP AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

This response is submitted in reply to the Final Office Action in the above-captioned
application mailed on November 2, 2006, having a three-month statutory period for response set
to expire on February 2, 2007, Applicants respond as follows.